



Empa

Materials Science and Technology

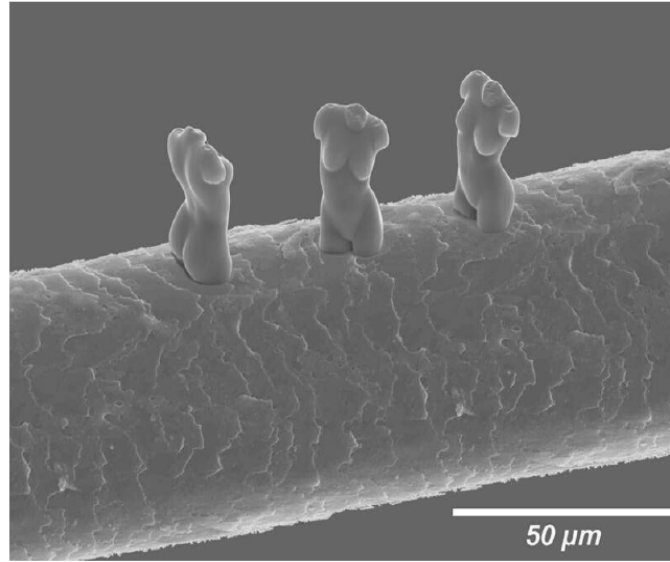
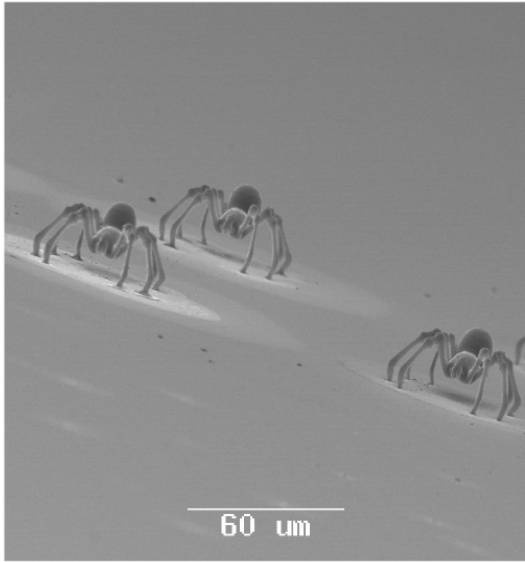


ÉCOLE POLYTECHNIQUE
FÉDÉRALE DE LAUSANNE

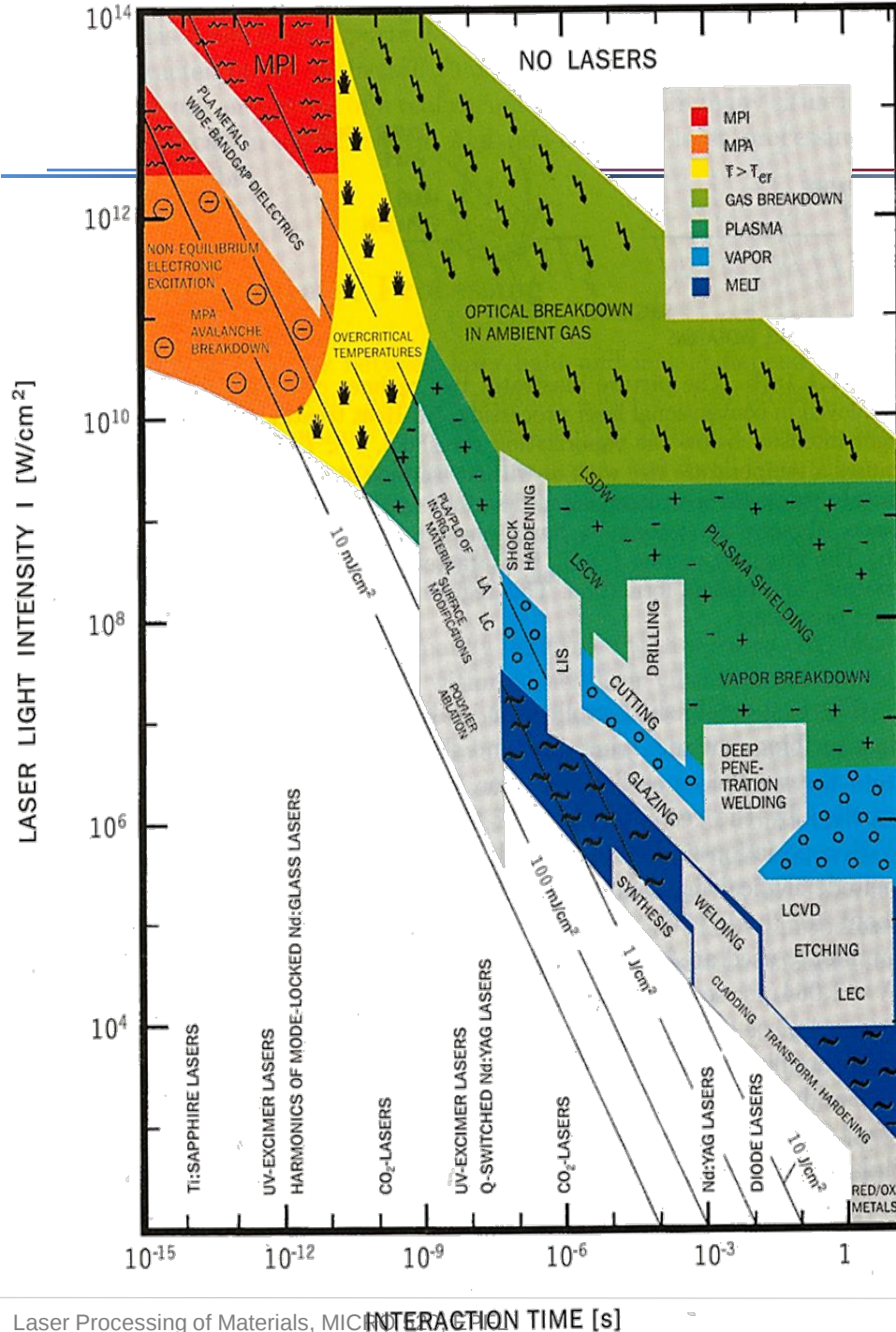
Laser Processing of Materials

Generating Techniques

Patrik Hoffmann



Direct Metal Laser Sintering (DMLS) | © 2012 Solid Concepts Inc.



What kind of laser do you propose for bending / welding?

Application of lasers in materials processing:

Intensity-Time Diagram

PLA/PLD – pulsed laser ablation/
deposition

LA – laser annealing

LC – laser cleaning

LIS – laser induced isotope separation/IR –
laser photochemistry

MPA/MPI – multiphoton absorption
ionization

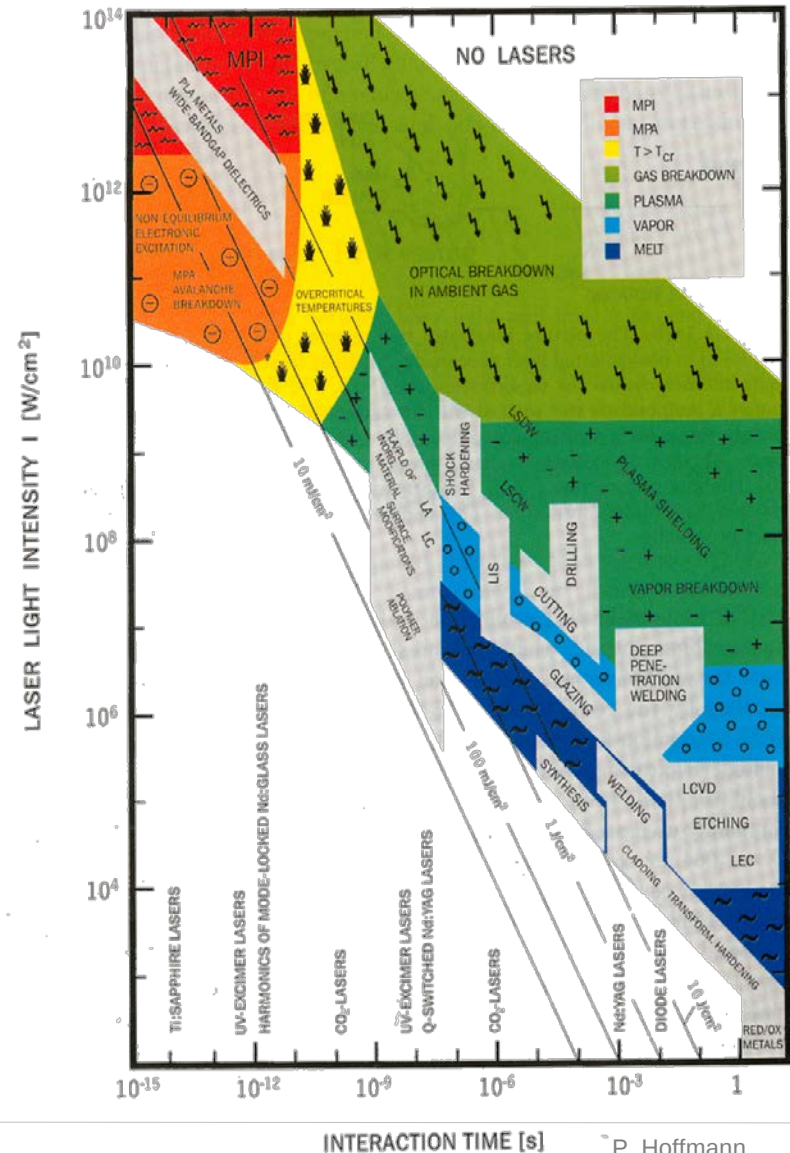
LSDW/LSCW – laser supported
detonation/combustion waves

LCVD – laser induced chemical vapour
deposition

LEC – laser induced electrochemical
plating/etching

RED/OX – long pulse or cw CO₂-laser
induced reduction/oxidation

D. Bäuerle; Laser Processing and
Chemistry, 3rd ed. Springer, Berlin,
2000



Laser Types: Pulsed & CW

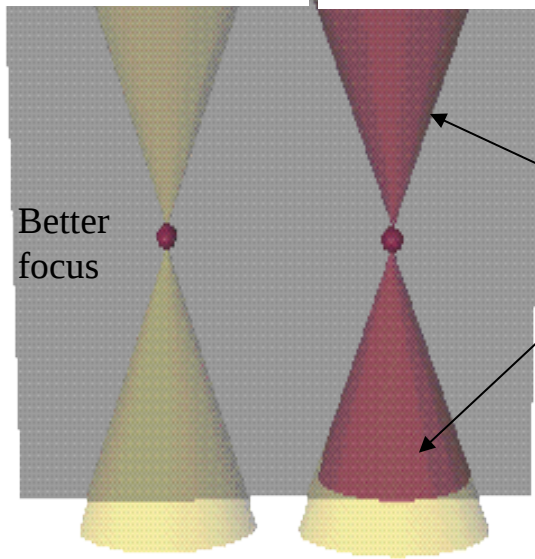
Type of laser	Pulse length determined by	Typical pulse length	Characteristic pulse peak power
Continuous wave (cw)	-	∞	Ws – kWs
Free running laser	Pump pulse length (flash lamp)	100 μ s – 1ms	kWs
Q-switched laser	Time constants of active material and modulating element	1 ns – 100 ns	MWs
Mode-locked laser	Number of coupled modes, pulse compression	10 fs – 10 ps	GWs

Content

- Generating technologies
 - Laser powder sintering / melting
 - Micro-stereolithography

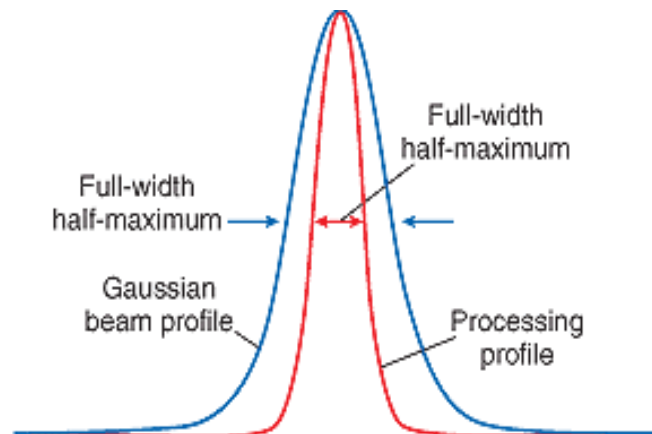
Multiphoton absorption

Multiphoton absorption Single photon absorption

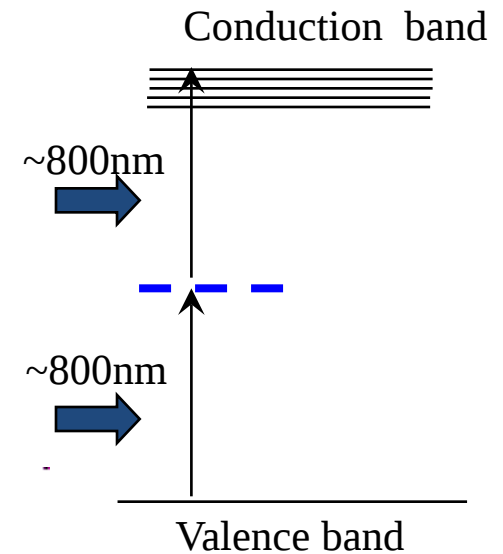


Optical power spreading

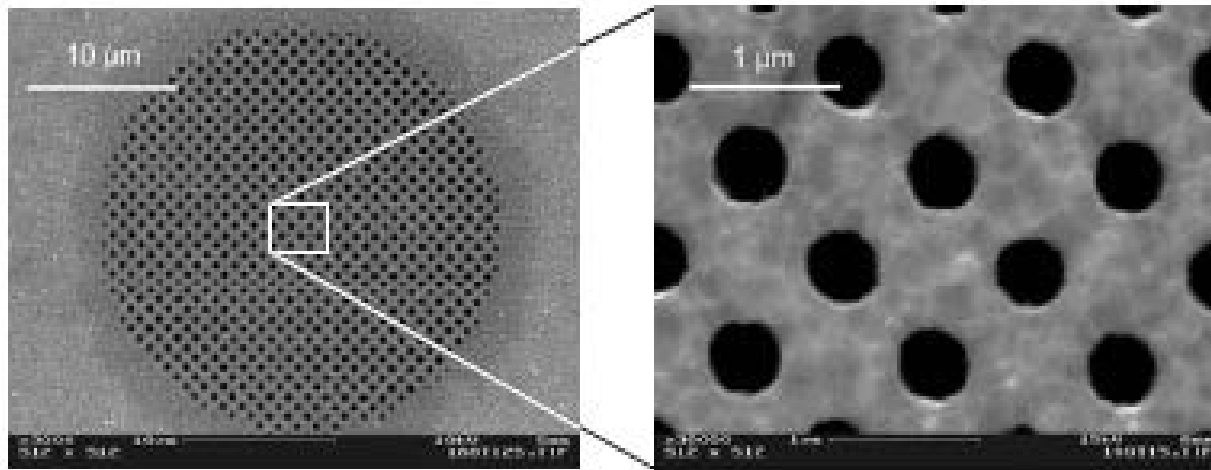
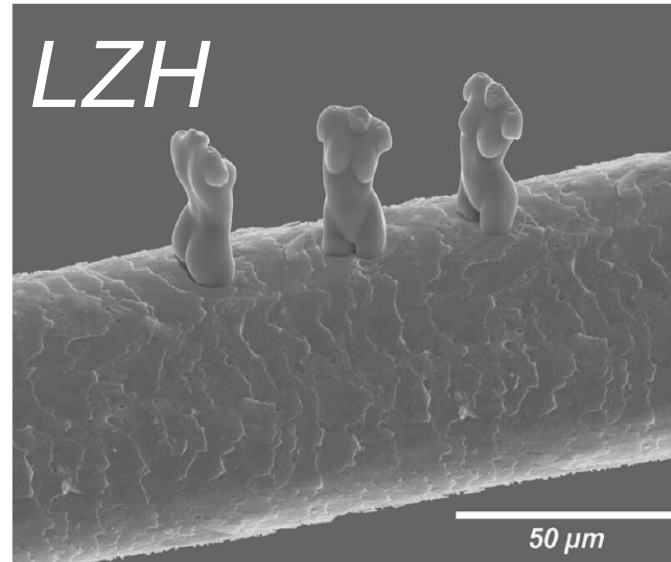
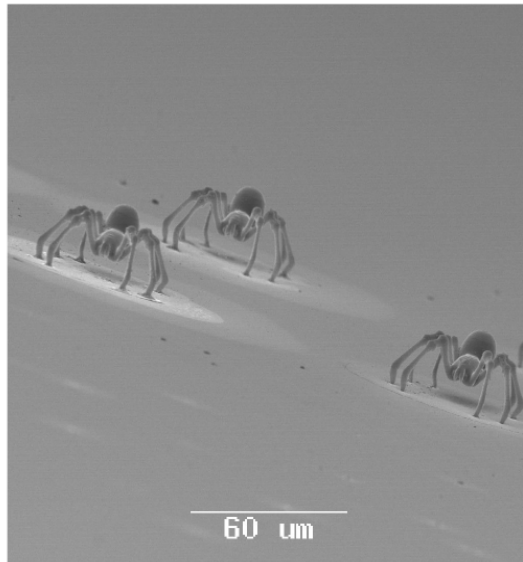
Better focus



Two photon absorption

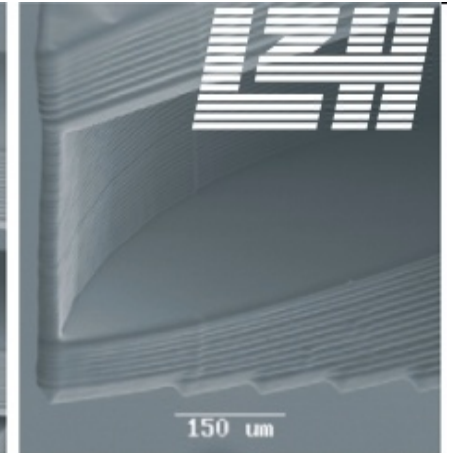
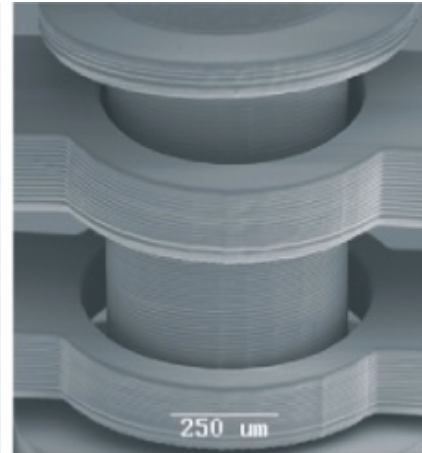
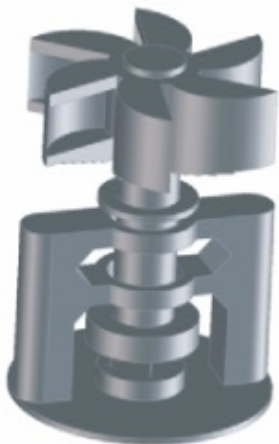
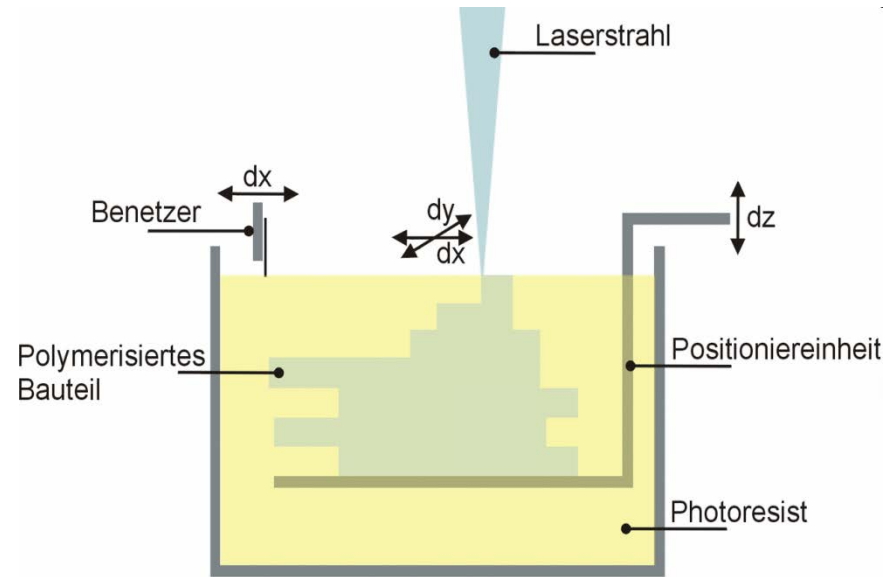


3D Polymerization (Multiphoton)



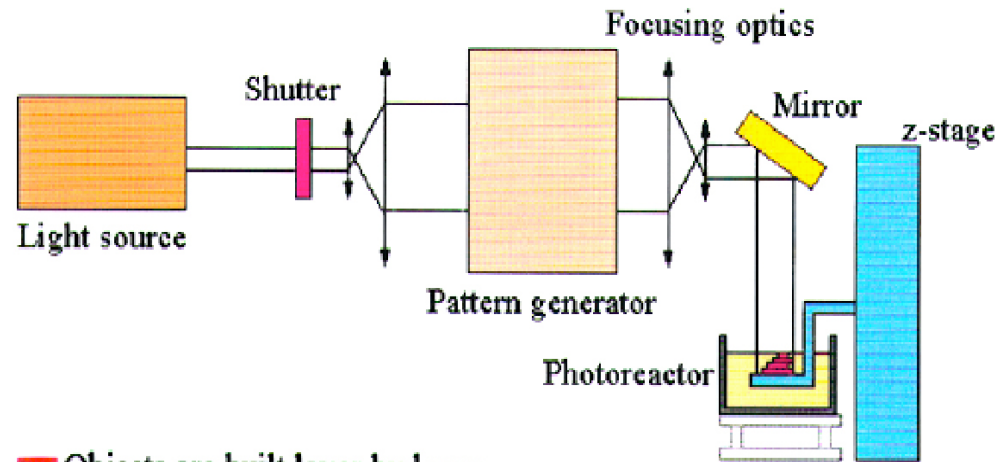
Klein-Wiele, J.H.; Bekesi, J.; Simon, P. *Appl. Phys. A* 79 (2004) 775.

Quasi 3D Polymerization



Stereo lithography

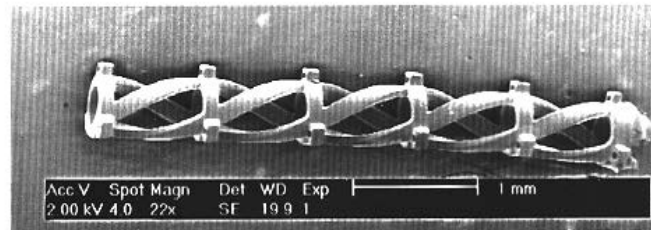
Principle of an integral microstereolithography apparatus



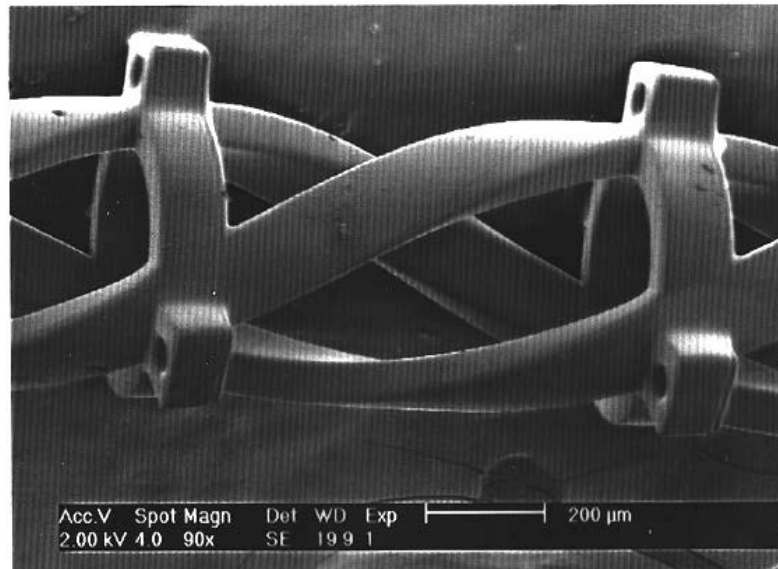
- Objects are built layer by layer
- A pattern generator is used to shape the light beam, so that it contains the image of the layer to be built
- This image is then focused and projected on the surface of a photopolymerizable resin
- A selective polymerization of the liquid resin occurs in the irradiated areas
- A shutter occults the light when a layer is solidified
- The object is then lowered in the photoreactor
- A new layer of fresh resin is spread on the surface of the already polymerized part of the object
- When the liquid surface is stabilized, the irradiation of the next layer can be started

Stereo Lithography

Imbricated springs made by microstereolithography



This structure is made of 1000 layers, each is $5\mu\text{m}$ thick.
Its total length is 5mm and its diameter $500\mu\text{m}$.
The fabrication time is approximately 5 hours.



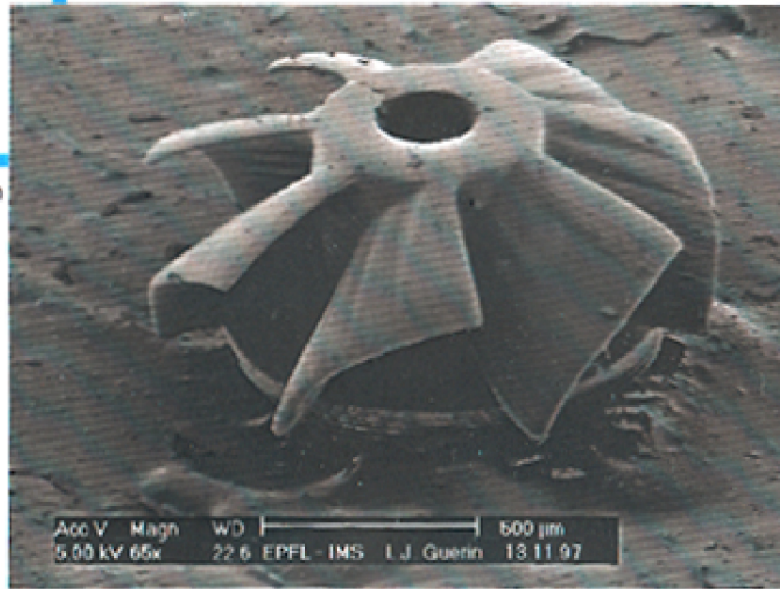
Detail of the springs: Note the smoothness of the surface.

Stereo lithography

Object generated with a CAD program and built by microstereolithography

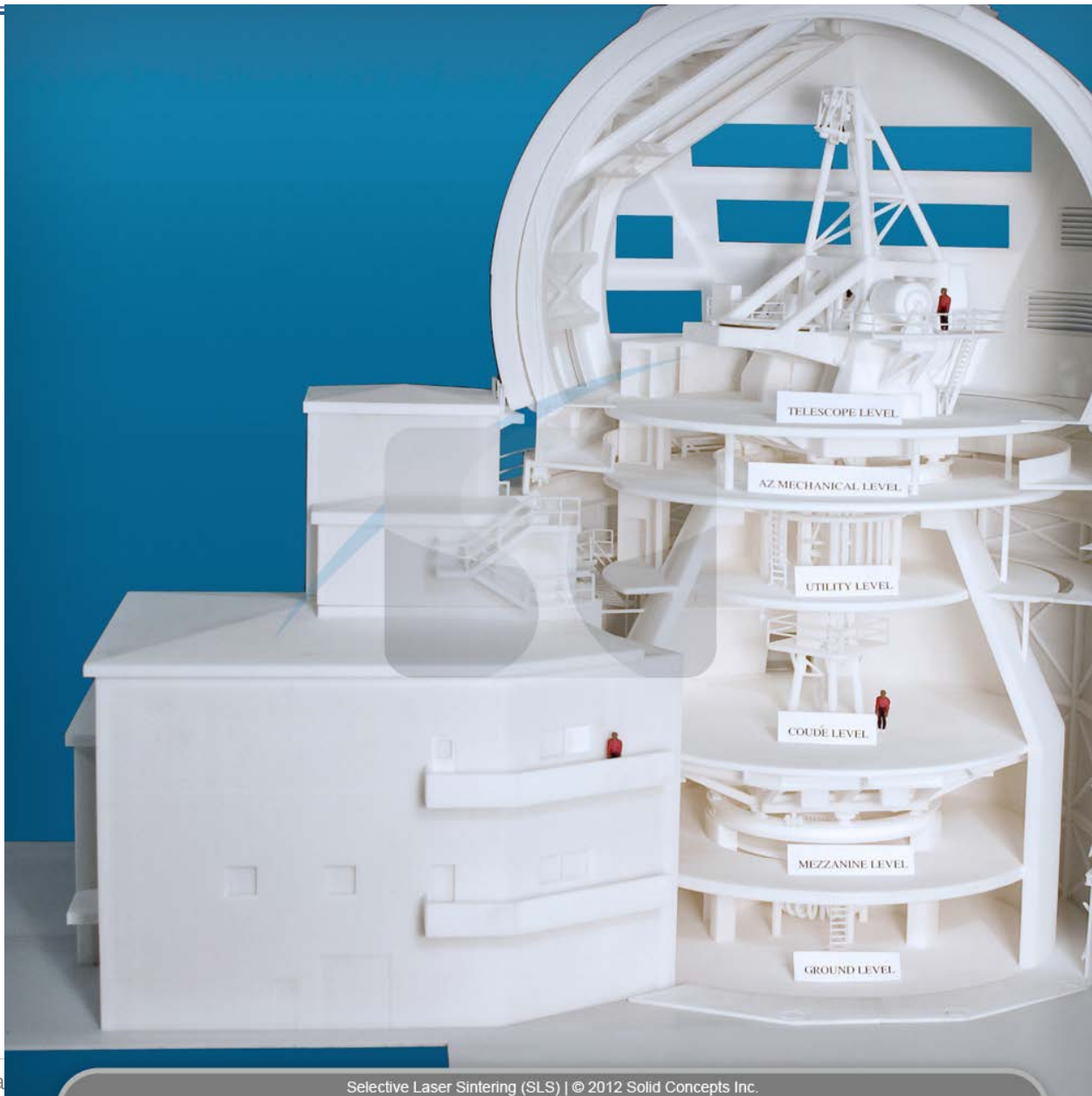


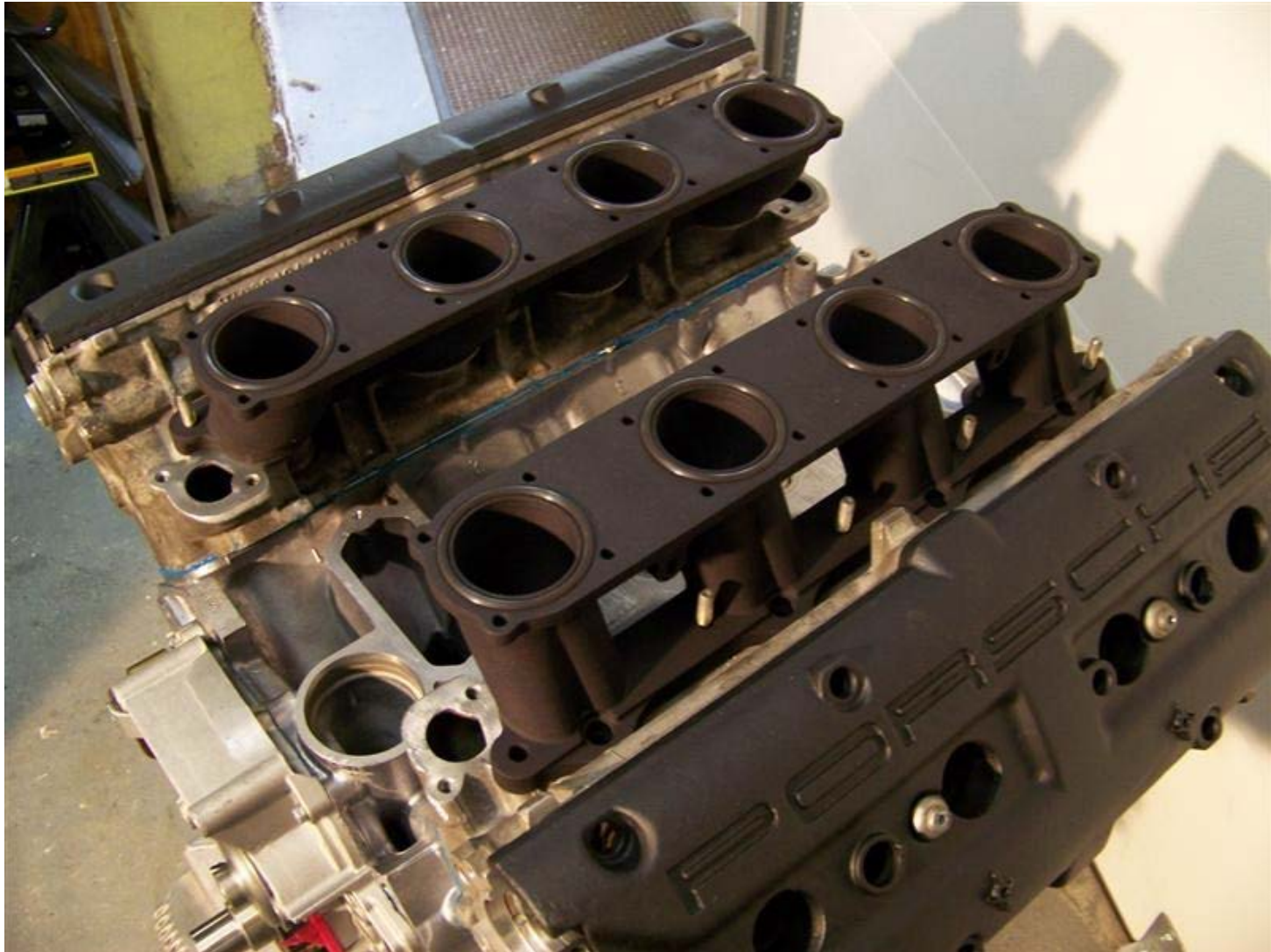
STL file of a turbine obtained with a CAD program



Micro turbine made by microstereolithography from a CAD file.
This object is 1.3mm in diameter and made of 120 layers of 5μm each









Laser Sintered copy of Browning 1911 pistol
stood at least 50 shots!

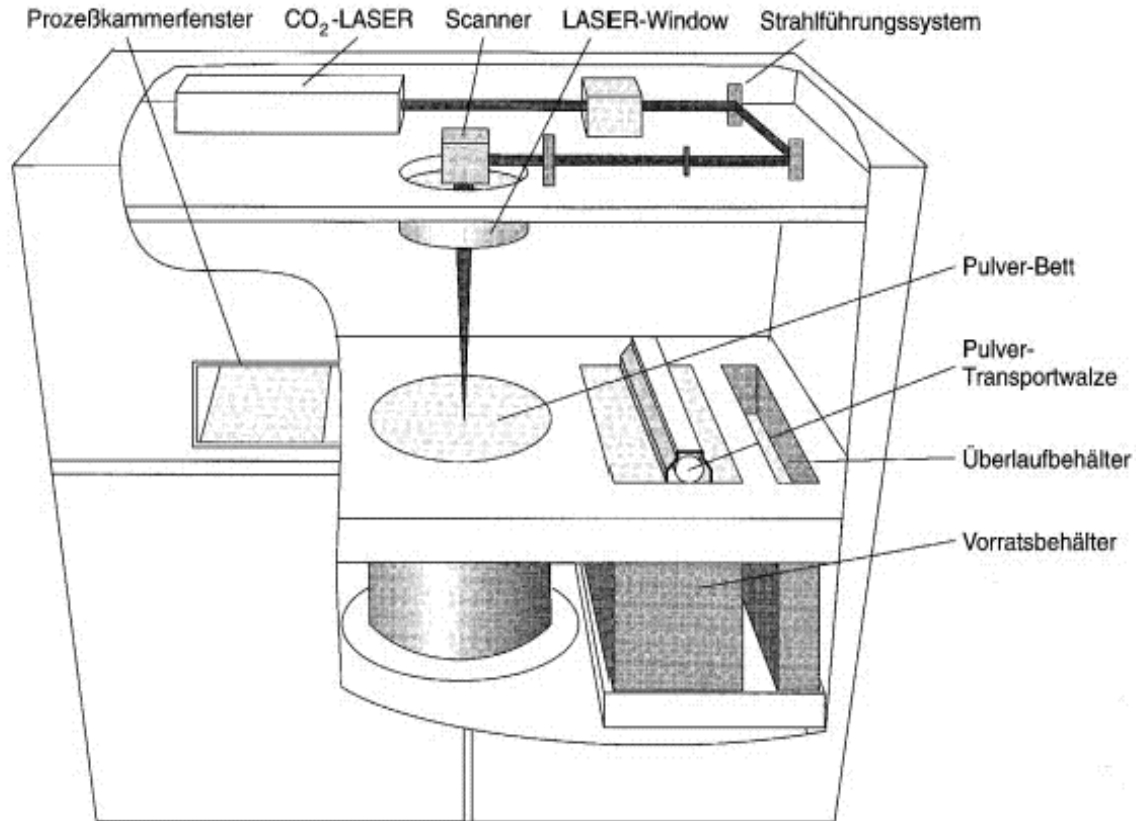


Laser sintered Titanium Heel

Laser Sintering

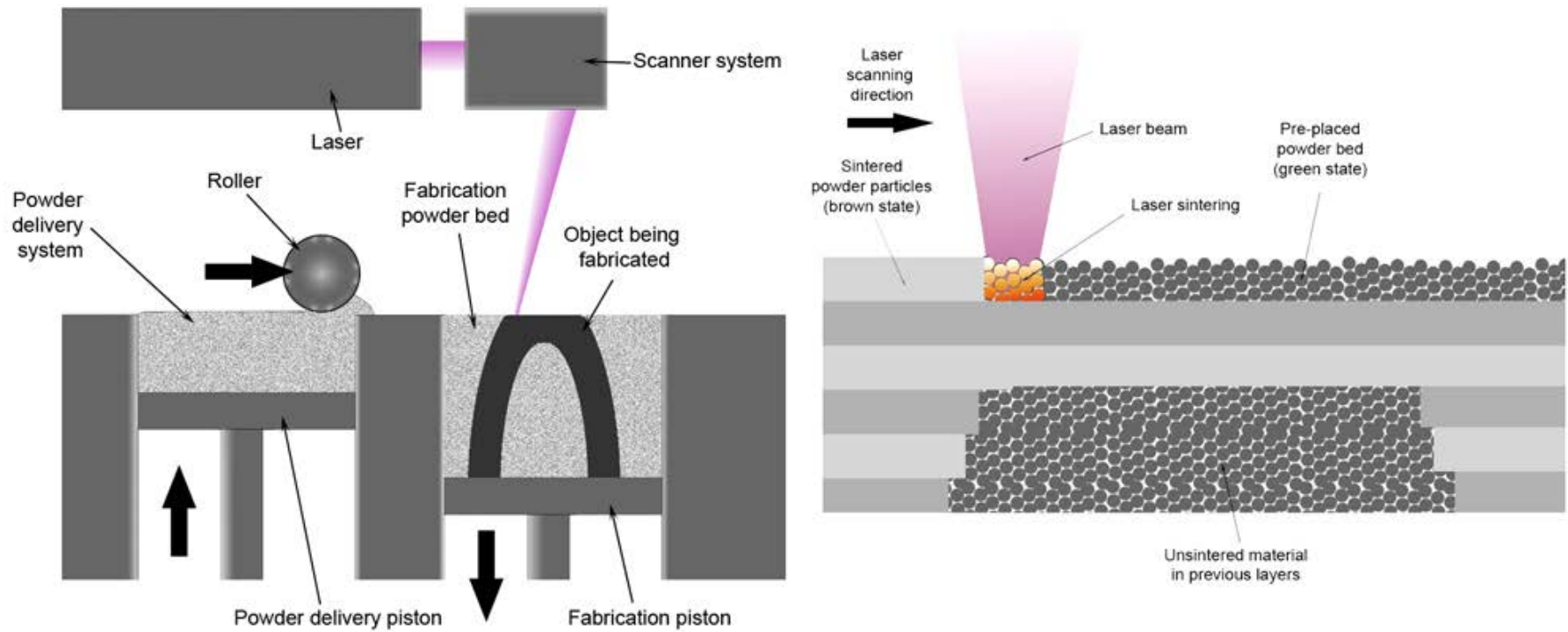
Lasertechnik II

Aufbau einer Lasersinteranlage



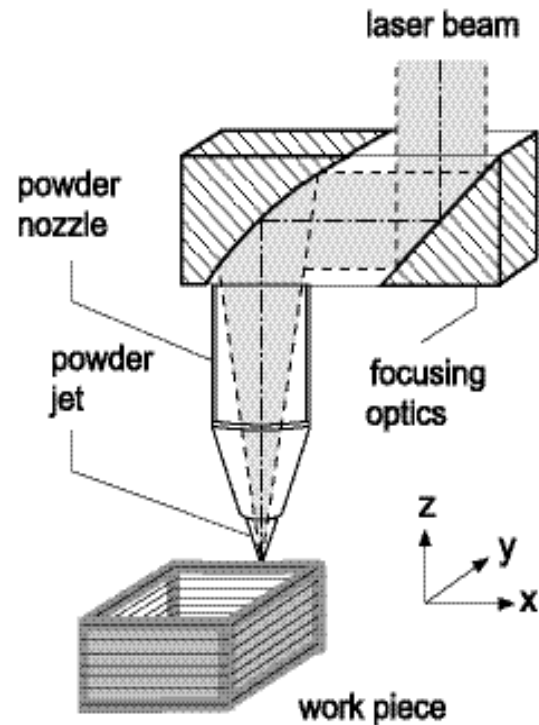
Quelle: LBBZ und DTM

Scheme of Selective Laser Sintering Machine

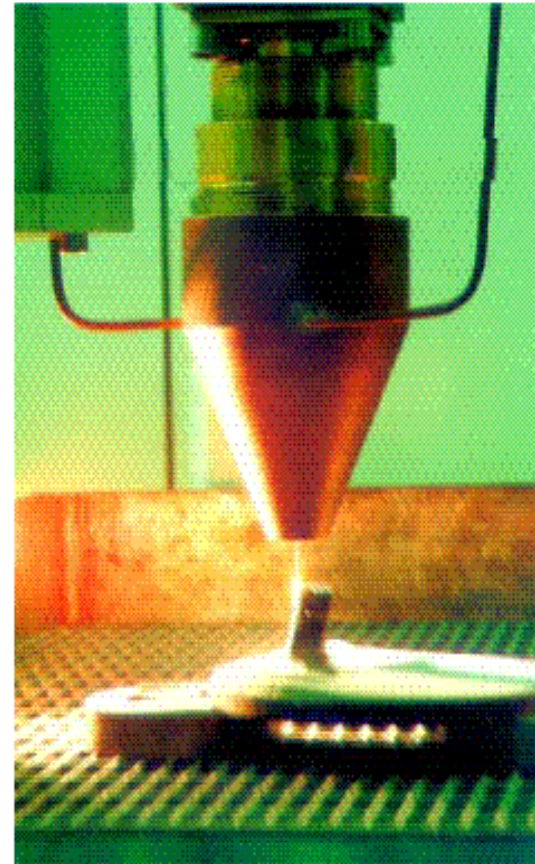


Laser assisted generating techniques

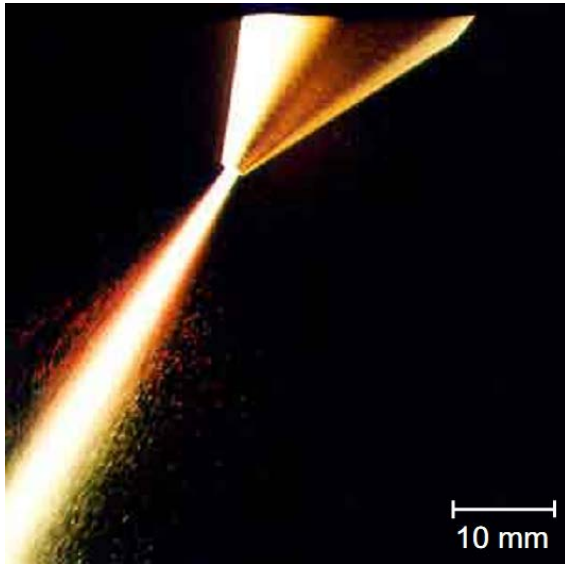
Direct production



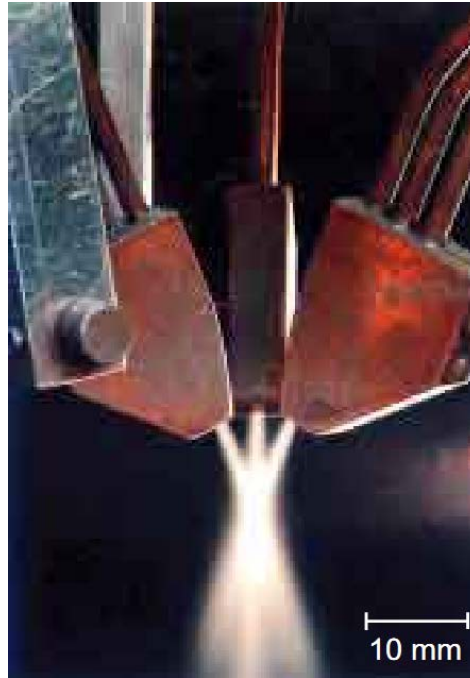
2 cm



Powder Gas Nozzle



Off-axis nozzle



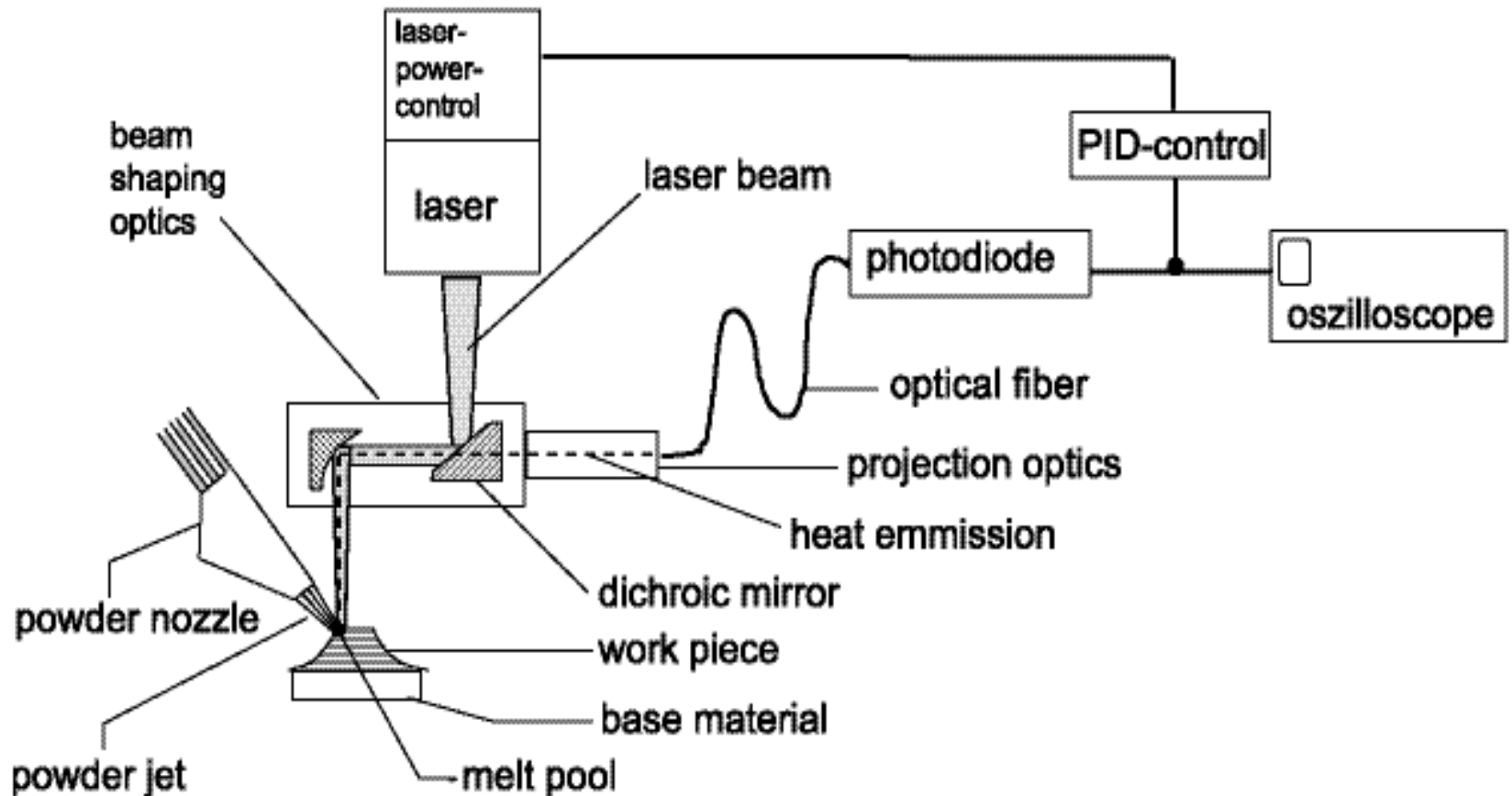
Multi beam nozzle



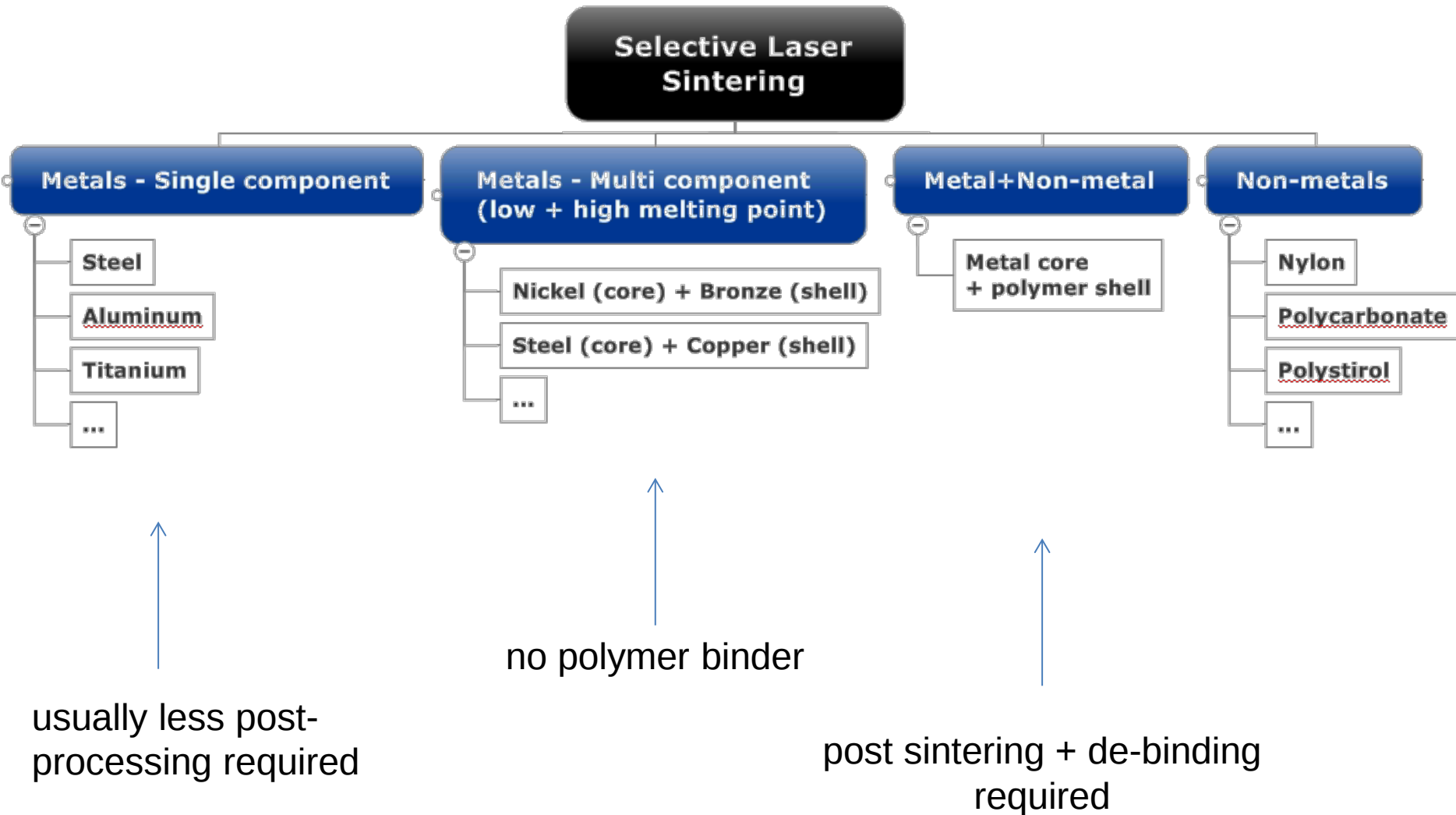
Coaxial nozzle

Laser assisted generating techniques

Principle of Temperatur-Control

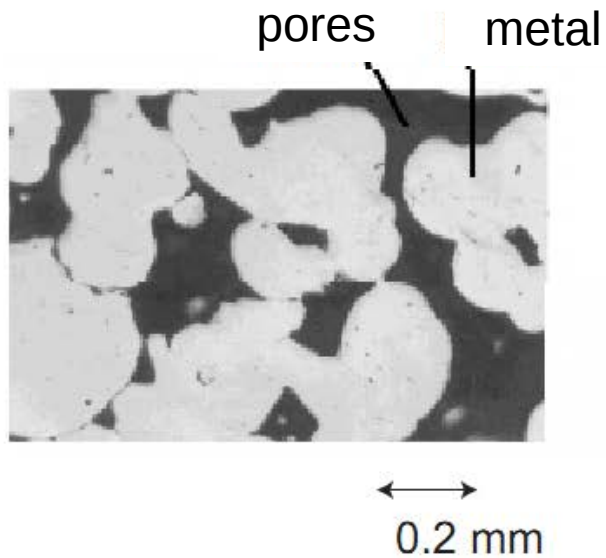


Selective Laser Sintering

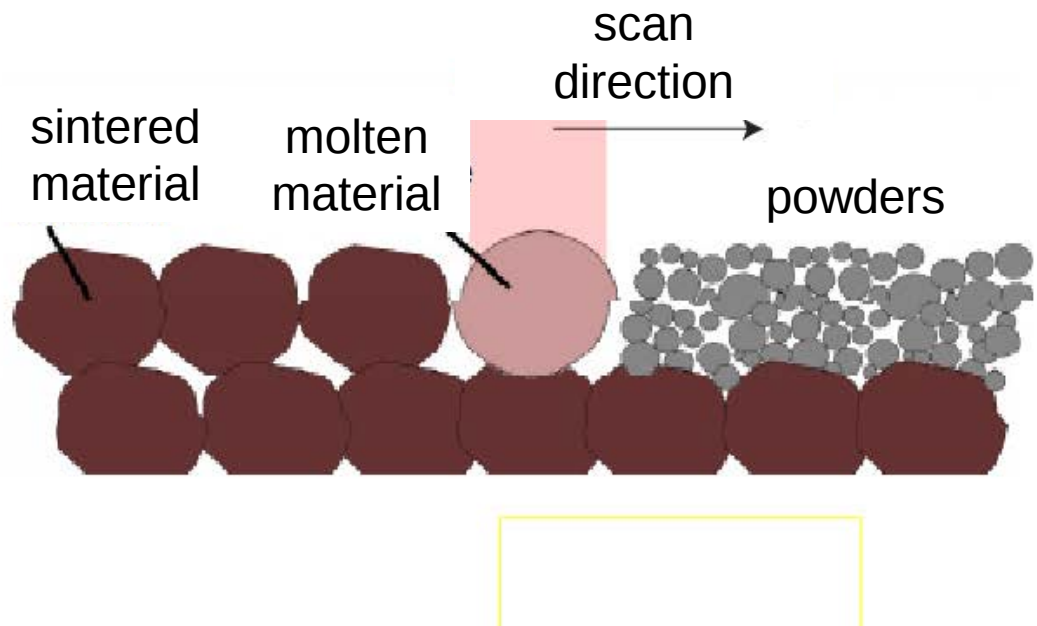


Pores Formation

Cross-section

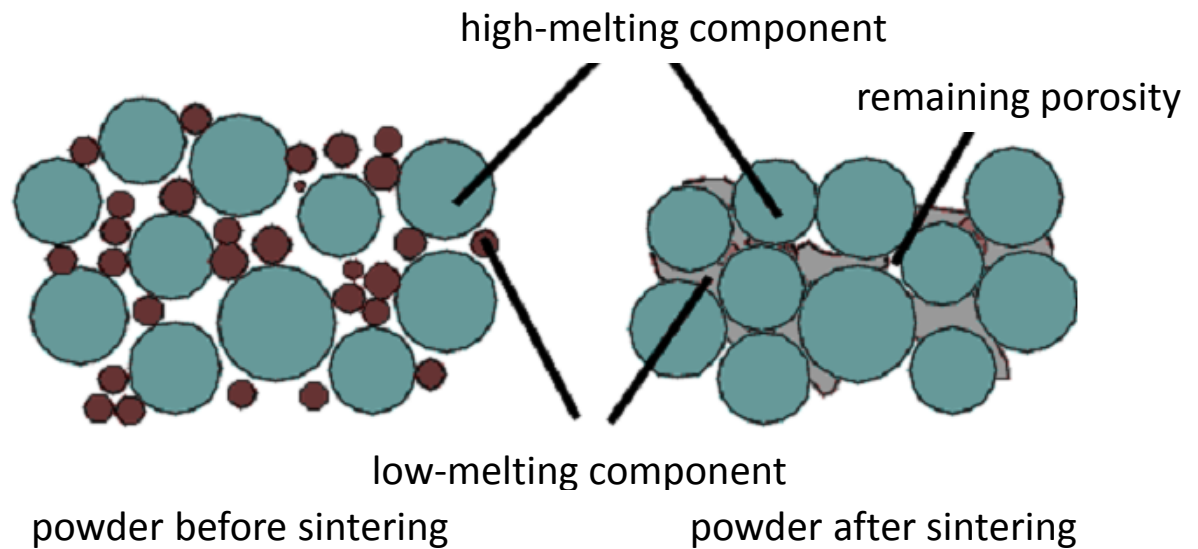
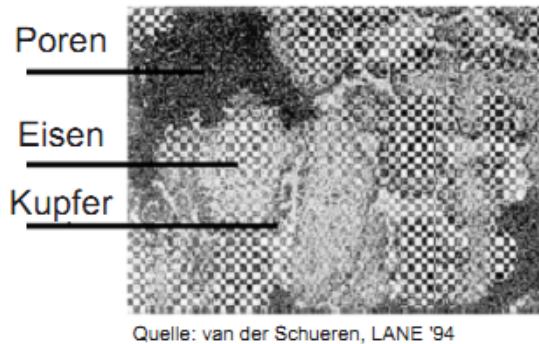


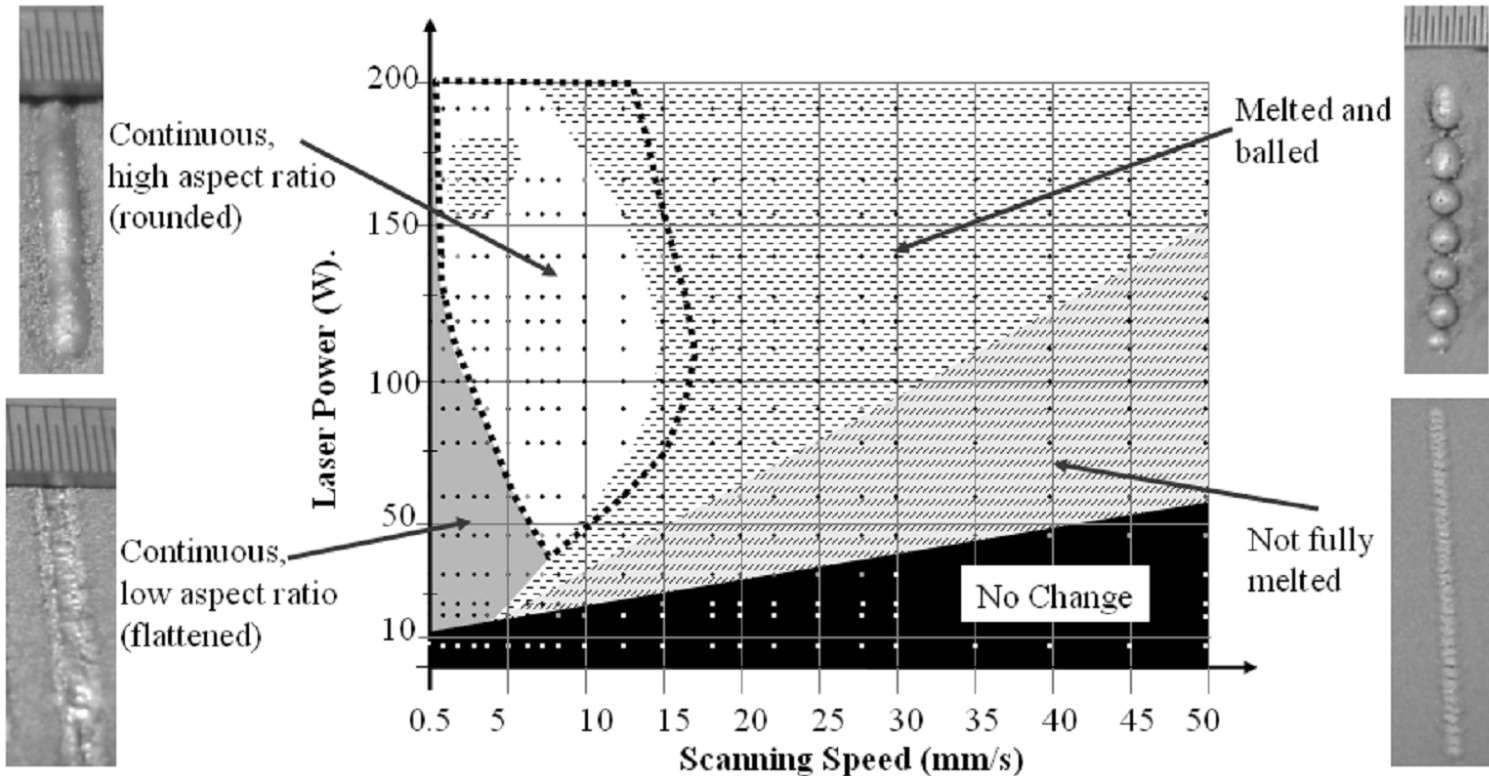
Scheme



Multi Component Powder Laser Sintering

Iron-Copper powder mixture
cross-section after processing

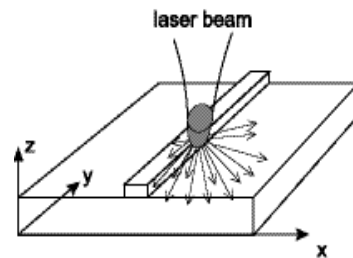




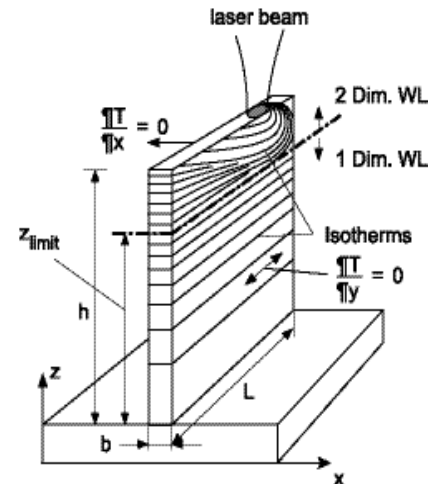
Laser assisted generating techniques

heat flow

1. layer



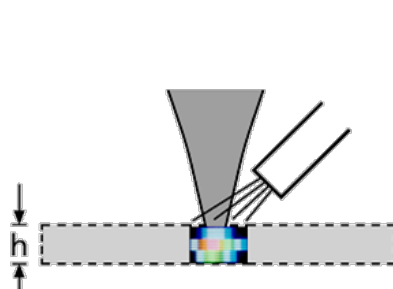
several layers



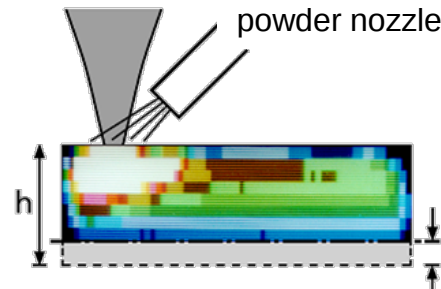
$z \gg 0 :$	$z \gg 0 \Rightarrow \frac{\partial T}{\partial x} = 0$	
three dimensional heat conduction	$z = h$	$z < z_{limit} \Rightarrow \frac{\partial T}{\partial y} = 0$
	two dimensional heat conduction	one dimensional heat conduction

Isotherms in the deposited thin wall

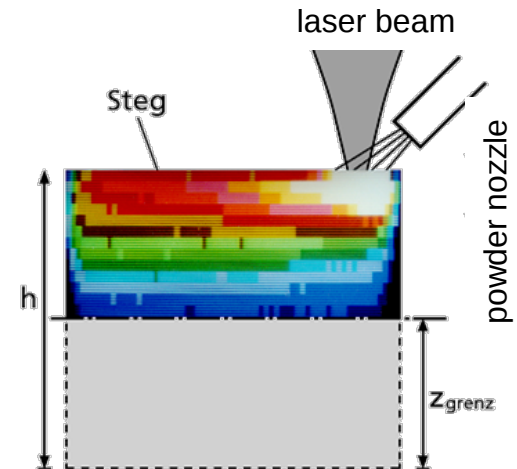
Laser power	$P=1\text{ kW}$
Powder feed-rate	$m=3.1\text{ g/min}$
Scan speed	$v=400\text{ mm/min}$
Layer height	$D_z=250\text{ }\mu\text{m}$
Wall width	$b=1.7\text{ mm}$
Wall length	$L=40\text{ mm}$
Material	Stainless steel 1.4404



5 Layers, $h=1.25\text{ mm}$



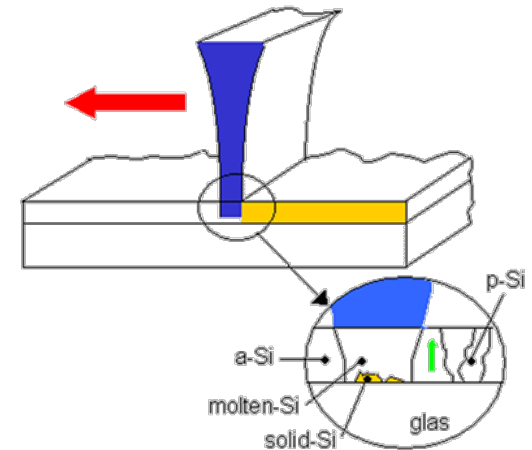
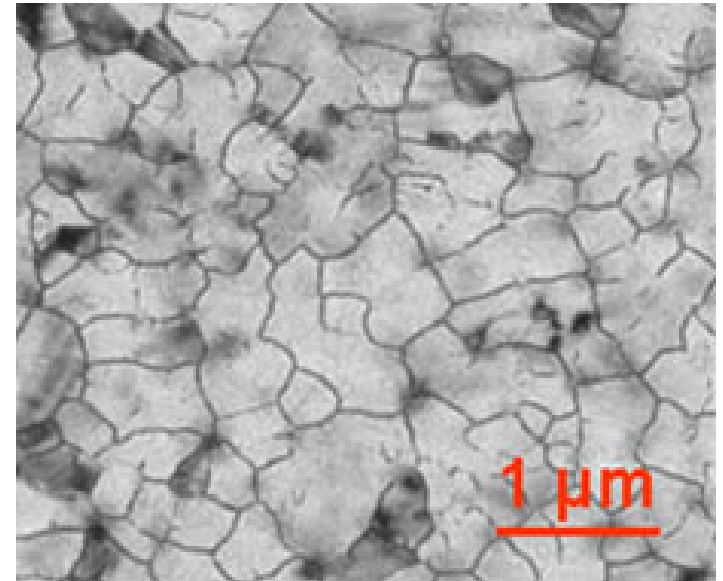
51 Layers, $h=1.3\text{ mm}$



150 Layers, $h=37.5\text{ mm}$

TFT Annealing – Si Recrystallization

Excimer laser treatment with XeCl at 308 nm



Schematic view of Excimer laser annealing transforming amorphous silicon of ca. 50 nm thickness into polysilicon.